

Supporting Information

Effective defect passivation with a designer ionic molecule for high-efficiency vapour-deposited inorganic phase-pure CsPbBr₃ perovskite solar cells

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Supplementary Figures

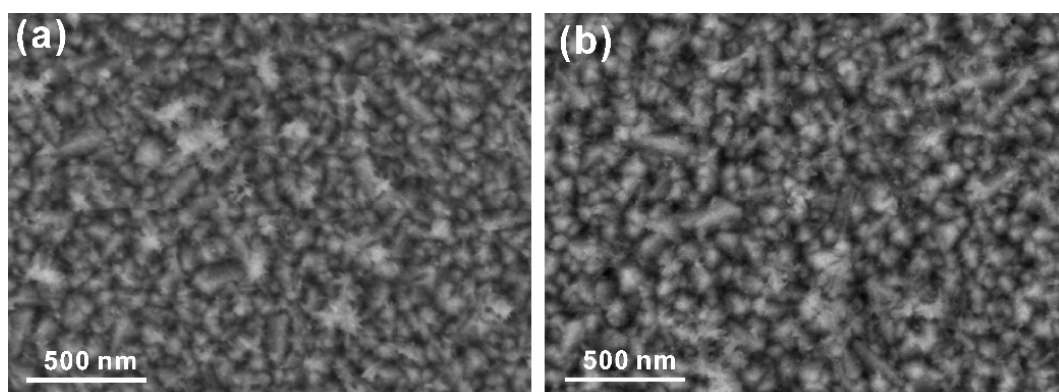


Fig. S1 The top-view of (a) TiO_2 and (b) TiO_2/DTPT films deposited on glass/FTO.

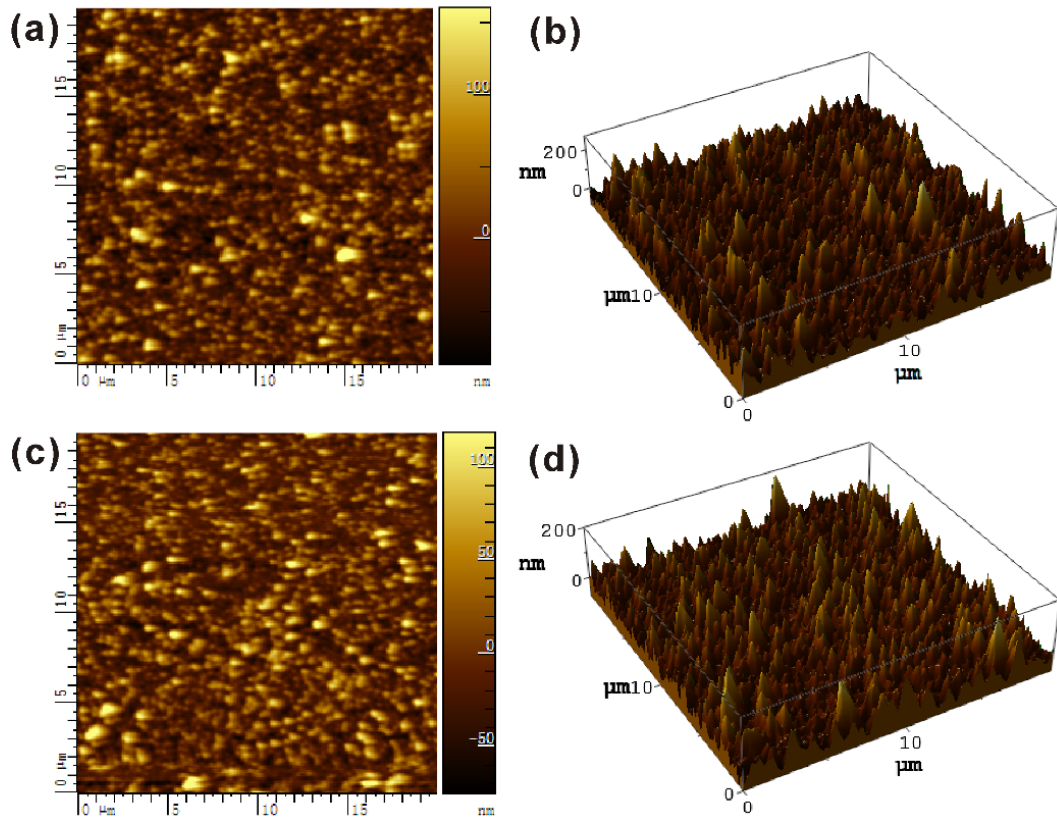


Fig. S2 AFM pictures of (a) TiO_2 and (c) TiO_2/DTPT films, corresponding 3D diagram.

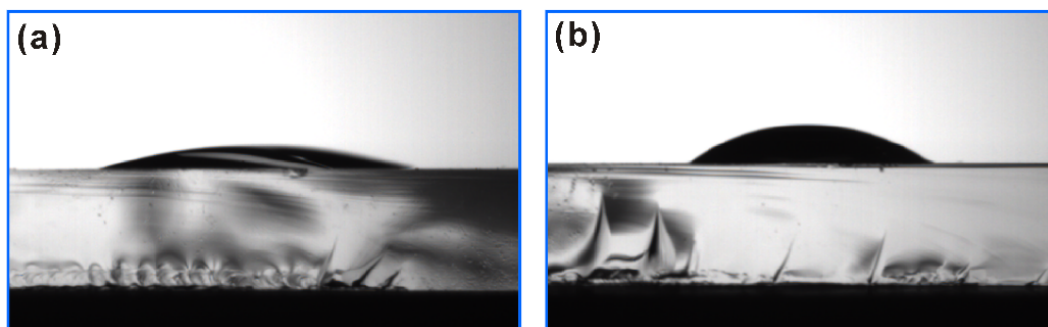


Fig. S3 The images show contact angle measurement of water and on (a) TiO_2 and (b) TiO_2/DTPT films.

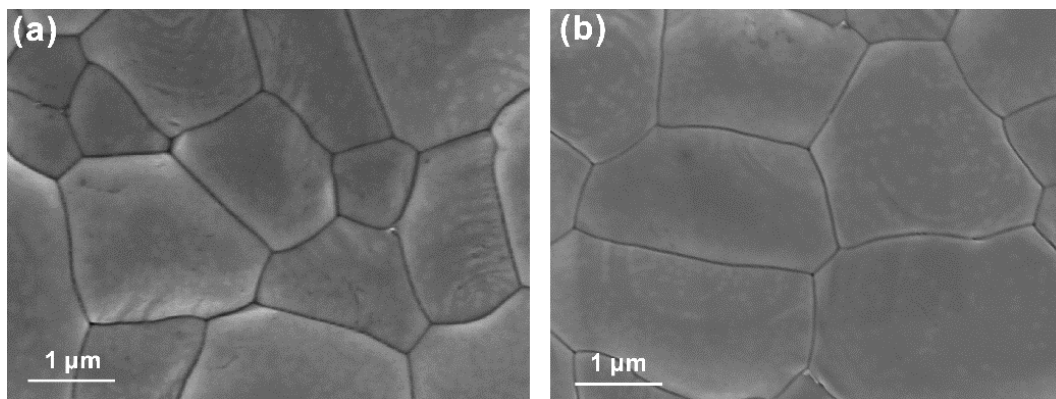


Fig. S4 Top view SEM images of CsPbBr₃ films based on (a) TiO₂ and (b) TiO₂/DTPT films.

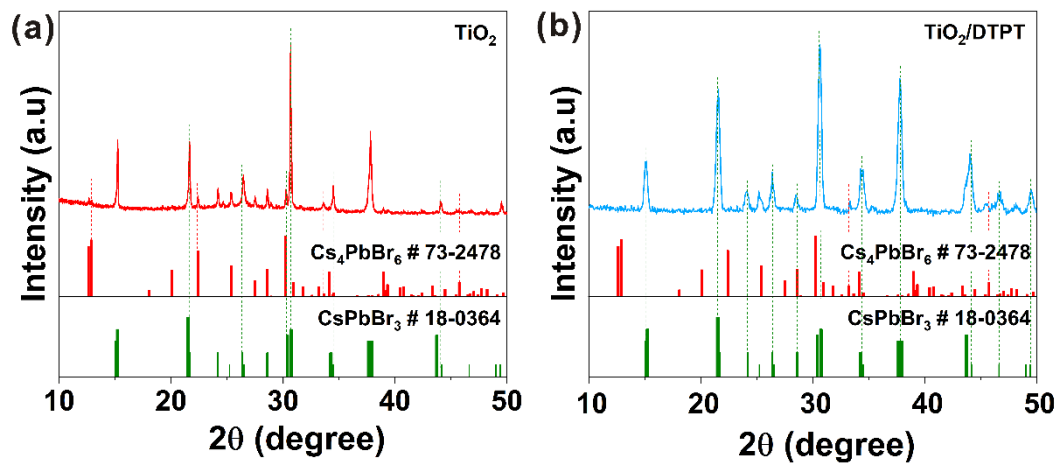


Fig. S5 XRD patterns of CsPbBr_3 films based on (a) TiO_2 and (b) TiO_2/DTPT films.

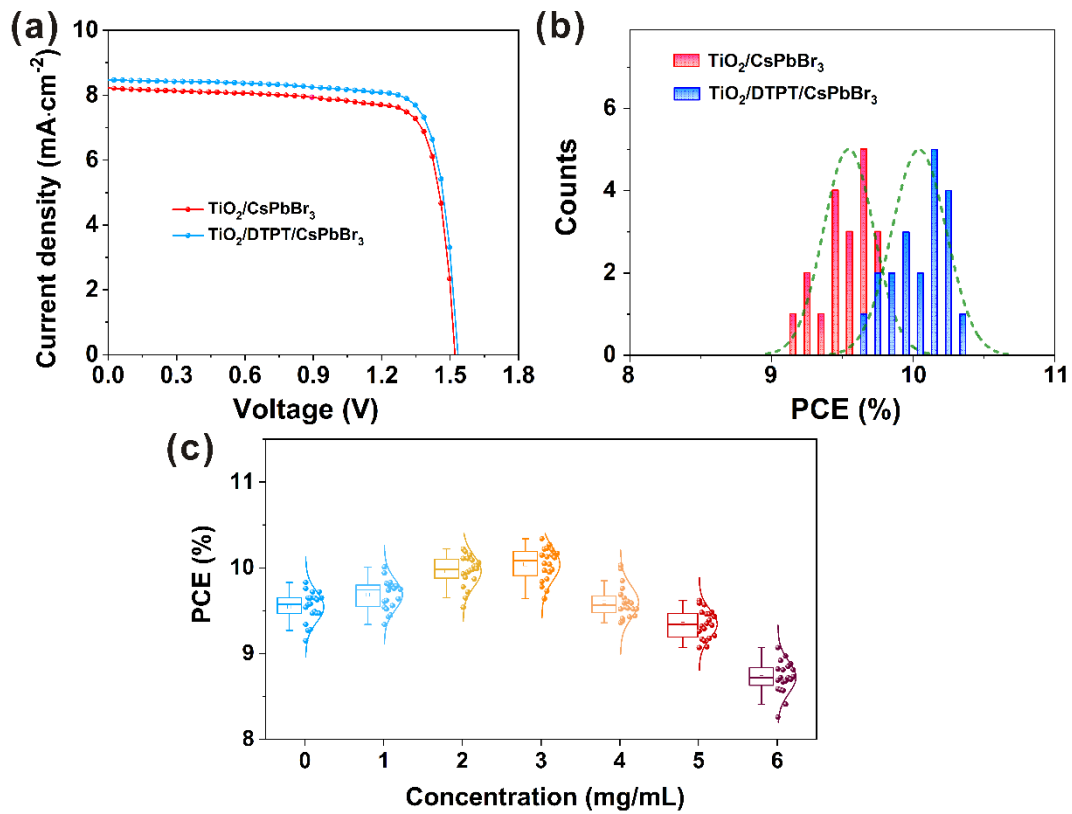


Fig. S6 (a) The J - V curves of PSCs and (b) histograms of PCEs measured (40 devices) based on TiO₂ and TiO₂/DTPT films. (c) The PCE statistics of devices for each DTPT concentrations deposited on TiO₂ films.

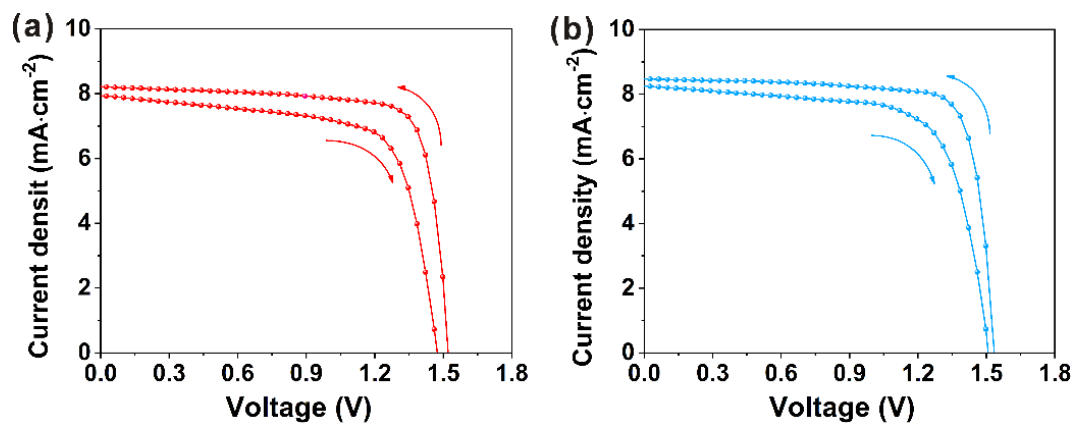


Fig. S7 Reverse scan and forward scan J - V curves of PSCs based on (a) TiO_2 and (b) TiO_2/DTPT films.

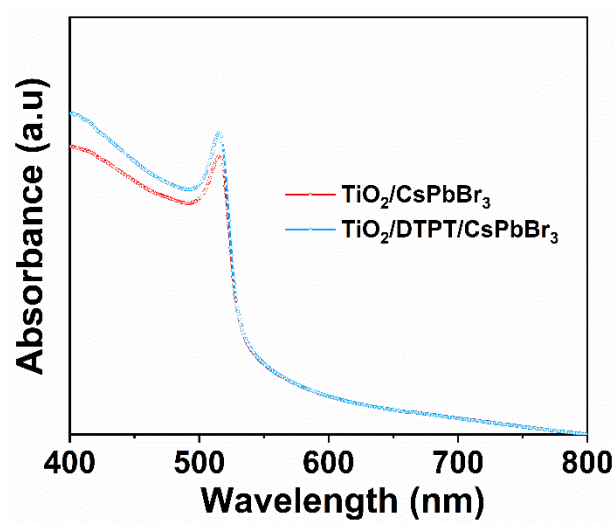


Fig. S8 Absorption spectra of CsPbBr₃ films deposited on TiO₂ and TiO₂/DTPT films.

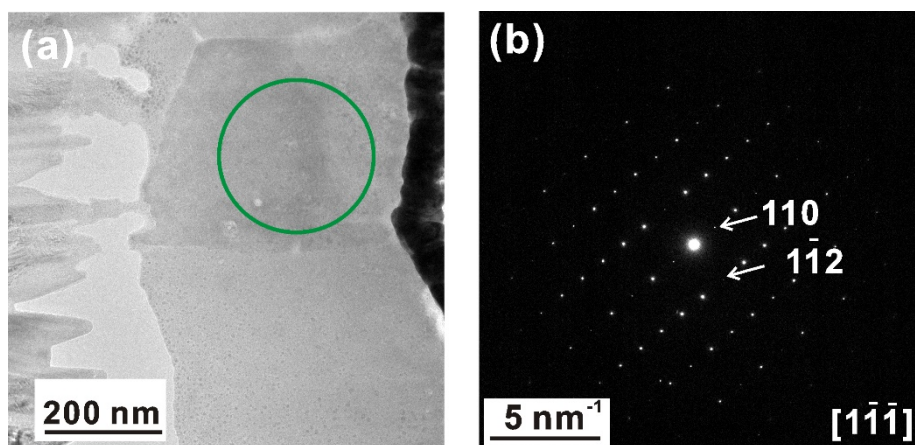


Fig. S9 (a) Cross-section TEM image of CsPbBr₃ film with DTPT treated and (b) its SAED in green circle in the TEM image.

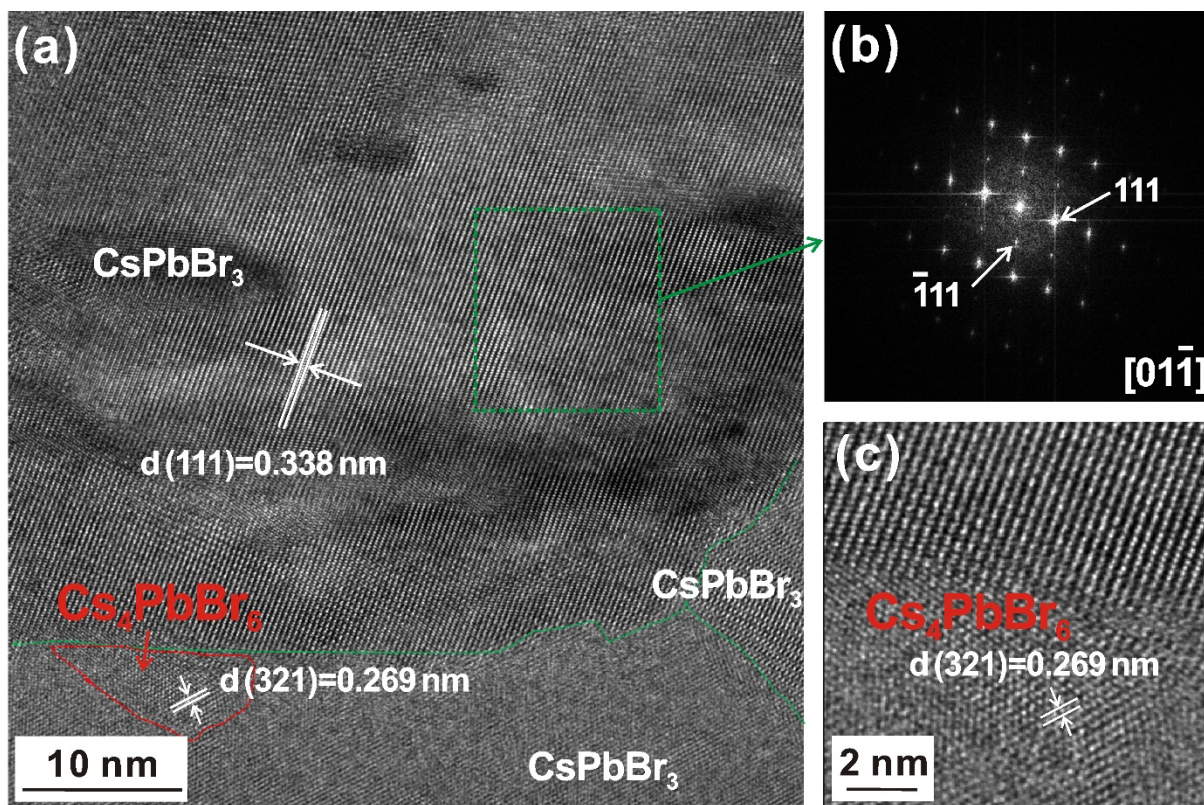


Fig. S10 (a) Planar-view high-resolution transmission electron microscopy (HRTEM) image, (b) FFT and (c) Partial enlargement image of $\text{TiO}_2/\text{DTPT}/\text{CsPbBr}_3$ film without top-surface DTPT treated.

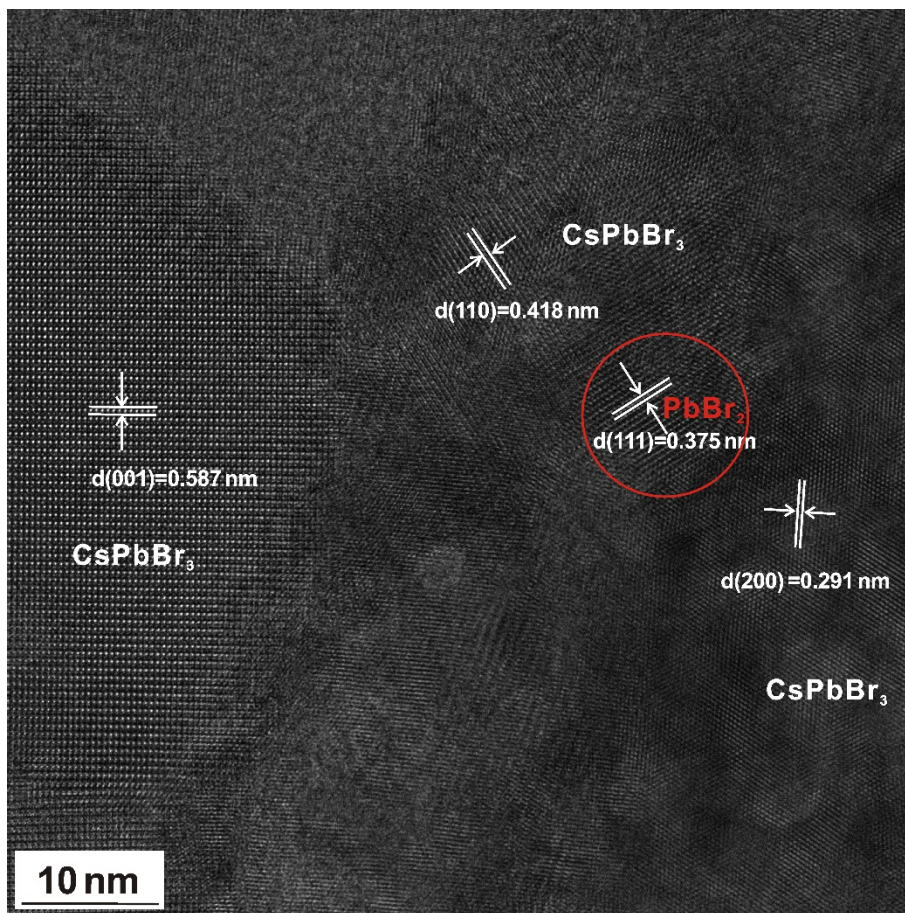


Fig. S11 Planar-view HRTEM image of $\text{TiO}_2/\text{DTPT}/\text{CsPbBr}_3$ film without top-surface DTPT treated.

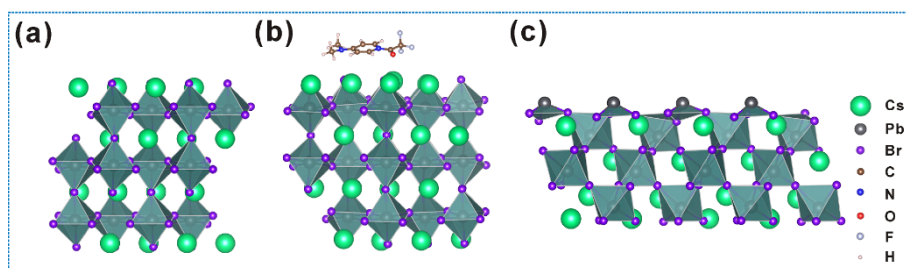


Fig. S12 The structures without and with DTPT on the surface. The (001) phase of CsPbBr₃ (a) without and (b) with DTPT on the surface; (c) The (110) phase of CsPbBr₃ without DTPT on the surface.

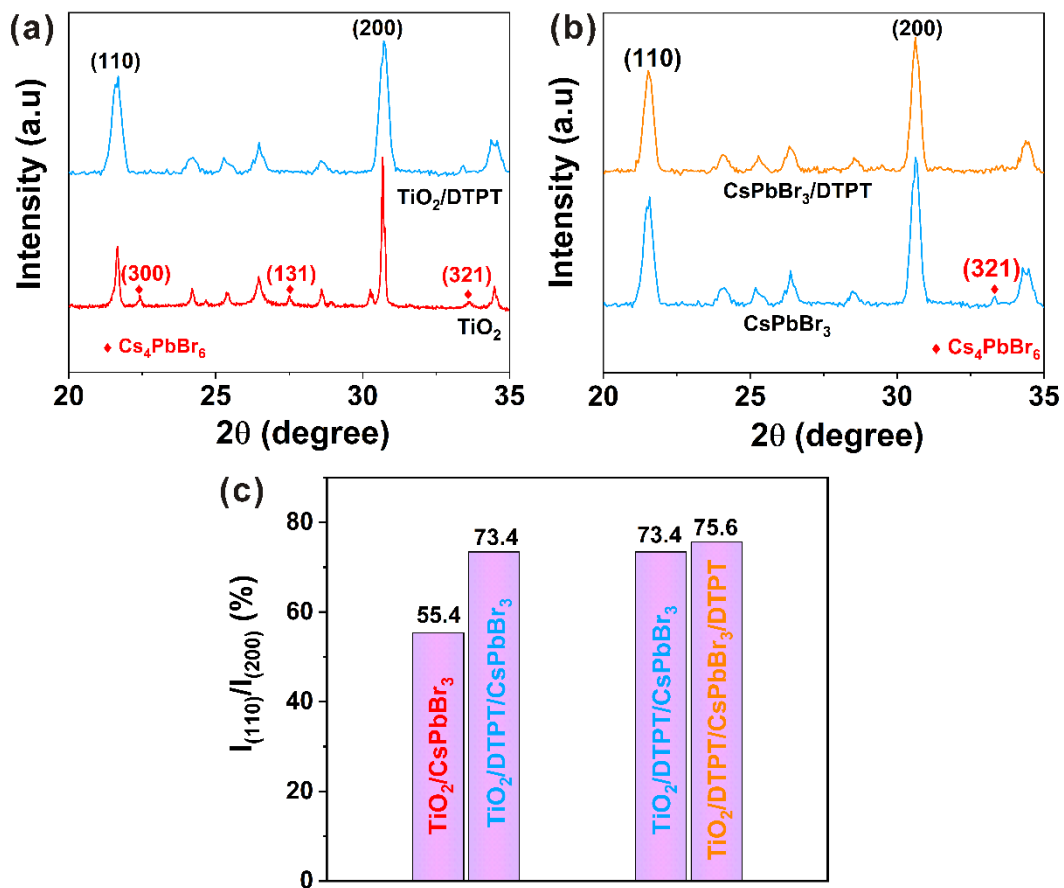


Fig. S13 The enlarged XRD spectra of CsPbBr_3 films deposited on (a) TiO_2 and TiO_2/DTPT films and (b) CsPbBr_3 and $\text{CsPbBr}_3/\text{DTPT}$ substrates; (c) The peak intensity ratio of (110) and (200) in $\text{TiO}_2/\text{CsPbBr}_3$, $\text{TiO}_2/\text{DTPT}/\text{CsPbBr}_3$ and $\text{TiO}_2/\text{DTPT}/\text{CsPbBr}_3/\text{DTPT}$ films.

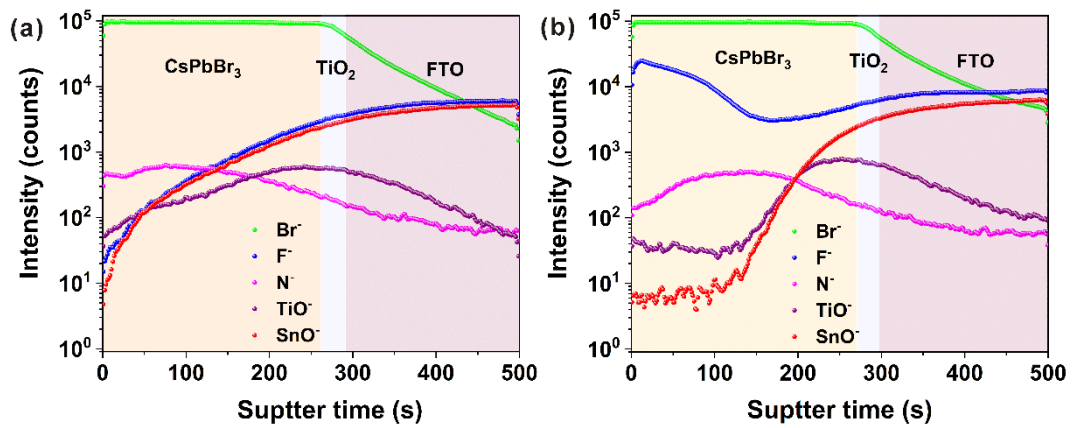


Fig. S14 ToF-SIMS depth profiles of the (a) CsPbBr₃ and (b) CsPbBr₃/DTPT films.

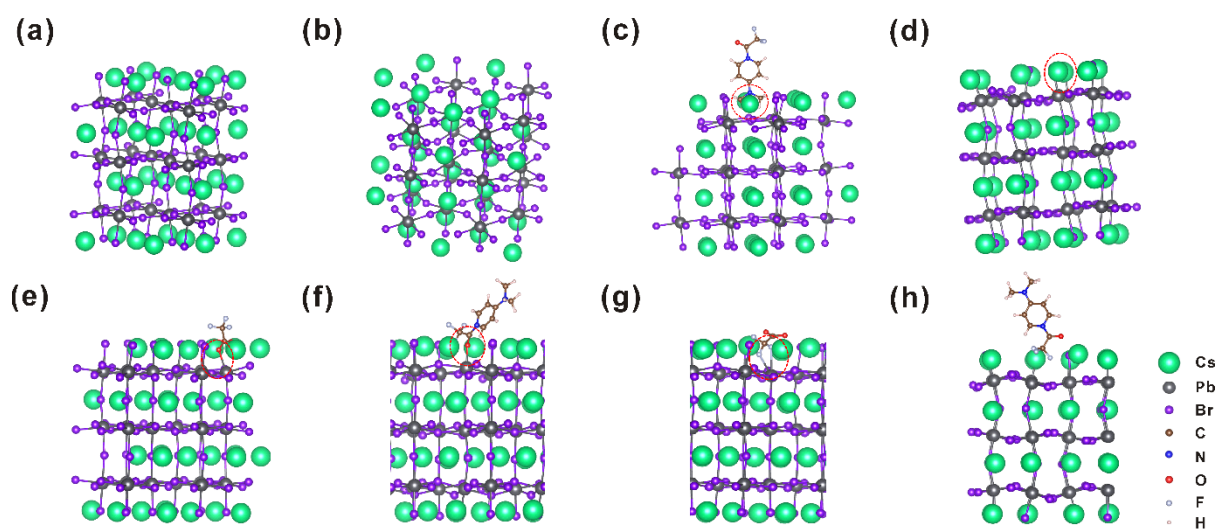


Fig. S15 The structures of the CsPbBr₃ with vacancies and passivated. (a) The pristine; (b) with V_{Cs} ; (c) V_{Cs} passivated by the DTPT; (d) with V_{Br} ; (e) V_{Br} passivated by the carboxylic acid group in CF_3COO^- ; (f) V_{Br} passivated by the C=O in DTPT; (g) V_{Br} passivated by the CF_3^- group in CF_3COO^- ; (h) V_{Br} passivated by CF_3^- group in DTPT.

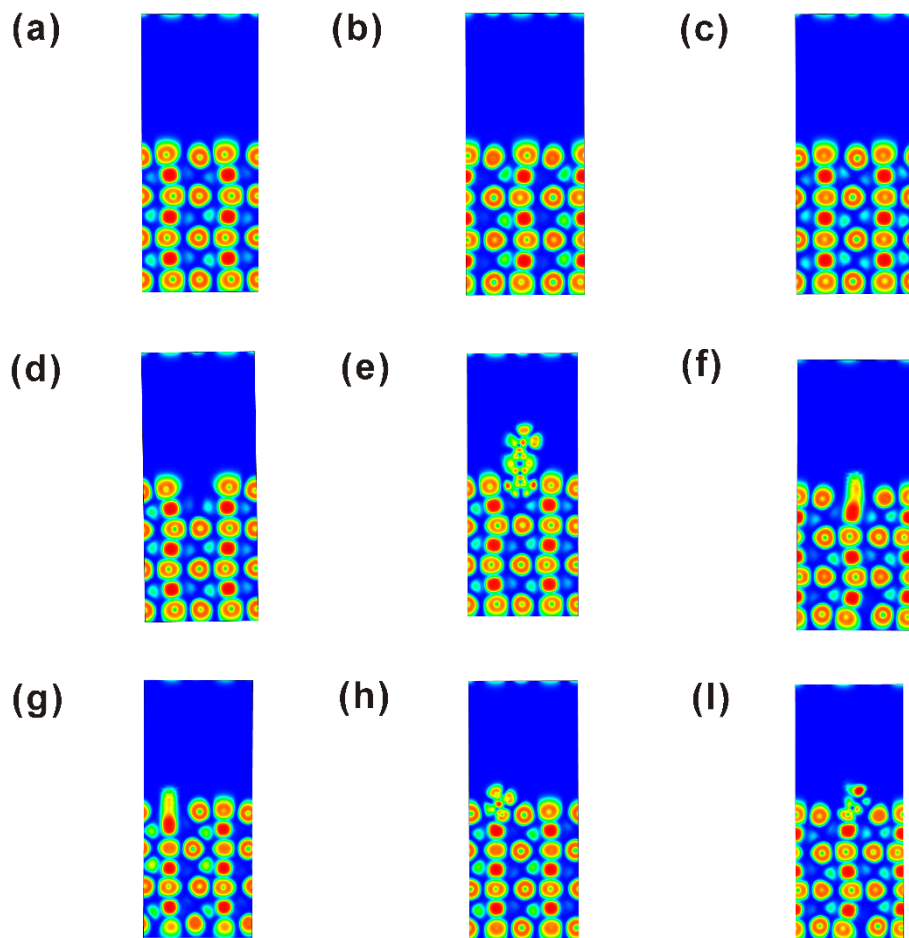


Fig. S16 Electron localization function (ELF) results of the CsPbBr₃ with vacancies and passivated. (a) 2D section (0 0.33 0) of the pristine CsPbBr₃; (b) 2D section (0 0.5 0) of the pristine CsPbBr₃; (c) 2D section (0.5 0 0) of the pristine CsPbBr₃; (d) 2D section (0 0.5 0) of the CsPbBr₃ with V_{Cs}; (e) 2D section (0 0.5 0) of the DTPT passivated CsPbBr₃ with V_{Cs}; (f) 2D section (0 0.33 0) of the CsPbBr₃ with V_{Br}; (g) 2D section (0 0.5 0) of the CsPbBr₃ with V_{Br}; (h) 2D section (0 0.33 0) of the CF₃COO⁻ passivated CsPbBr₃ with V_{Br}; (i) 2D section (0 0.5 0) of the DTPT passivated CsPbBr₃ with V_{Br}.

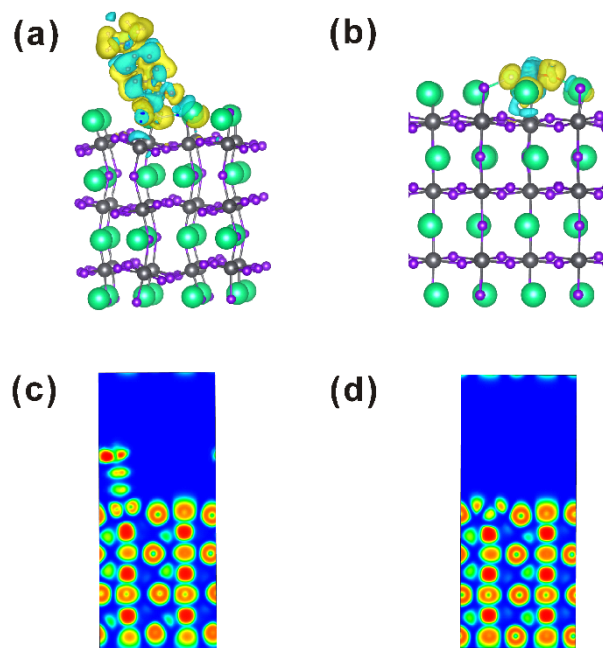


Fig. S17 The DFT result of the CsPbBr₃ with V_{Br} passivated by the CF₃⁻ group of DTPT. Differential charge density for (a) V_{Br} passivated by the CF₃⁻ group in DTPT and (b) V_{Br} passivated by the CF₃⁻ group in CF₃COO⁻; ELF results for (c) V_{Br} passivated by the CF₃⁻ group in DTPT and (d) V_{Br} passivated by the CF₃⁻ group in CF₃COO⁻.

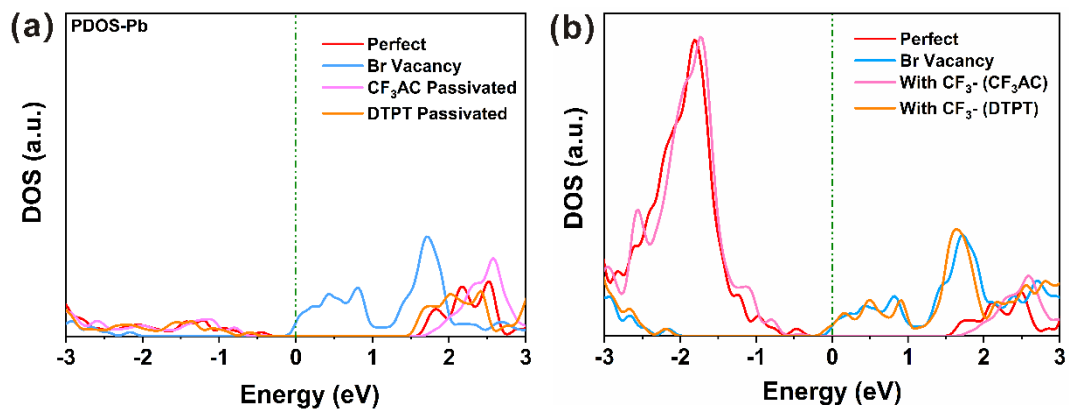


Fig. S18 Electronic partial density of state (PDOS) curves for Pb of the CsPbBr₃ with V_{Br} passivated by CF₃AC and DTPT;

(b) Density of state of CsPbBr₃ with V_{Br} passivated by the CF₃- group of CF₃AC and DTPT.

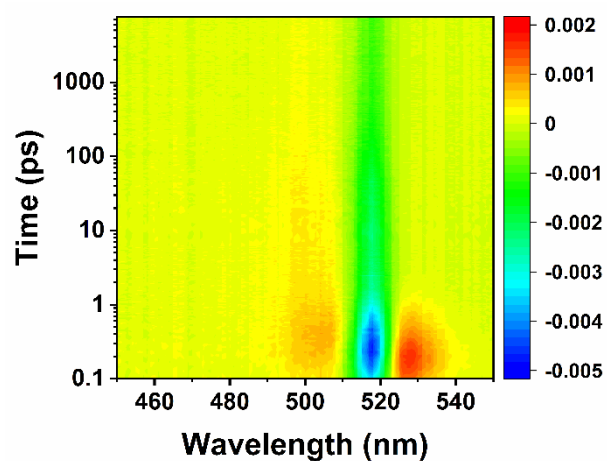


Fig. S19 Pseudo-colour femtosecond transient absorption (fs-T(A)) spectrum plots of CsPbBr₃ film upon a pulsed fs-laser excitation at 400 nm.

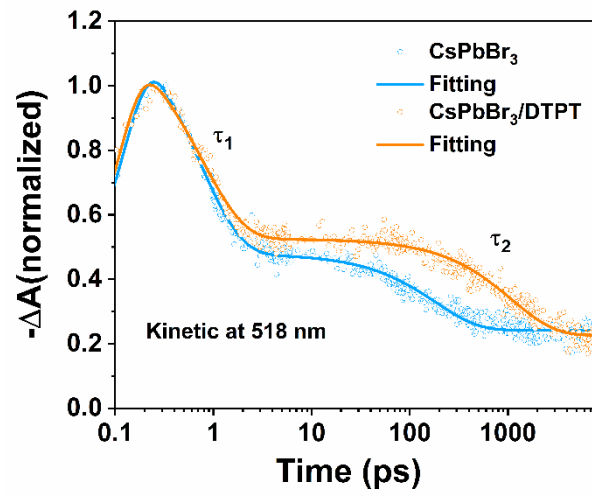


Fig. S20 Normalized bleaching kinetics at 518 nm of the CsPbBr_3 and $\text{CsPbBr}_3/\text{DTPT}$ films.

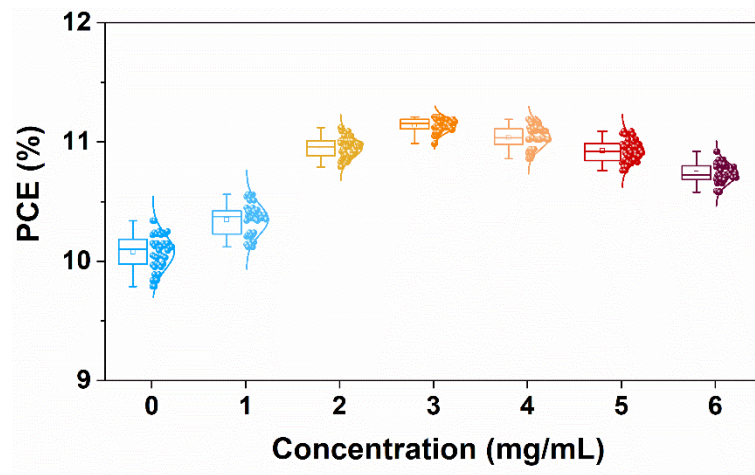


Fig. S21 The PCE statistics of 40 devices for each DTPT concentrations.

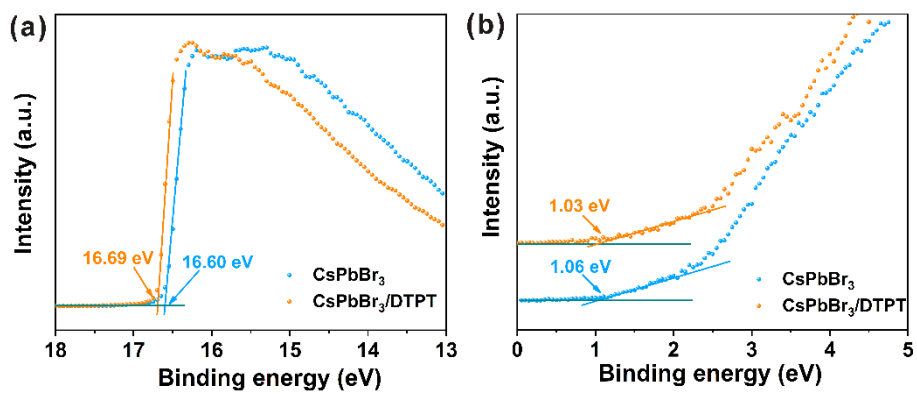


Fig. S22 (a) The cut-off energy ($E_{\text{cut-off}}$), (b) valence band maximum (VBM) edges of CsPbBr₃ and CsPbBr₃/DTPPT films.

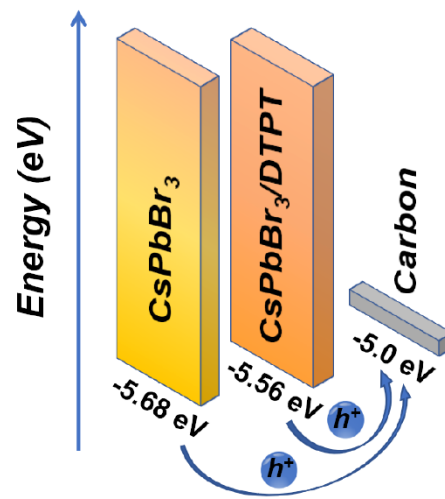


Fig. S23 Energy band of each isolated layer in the device.

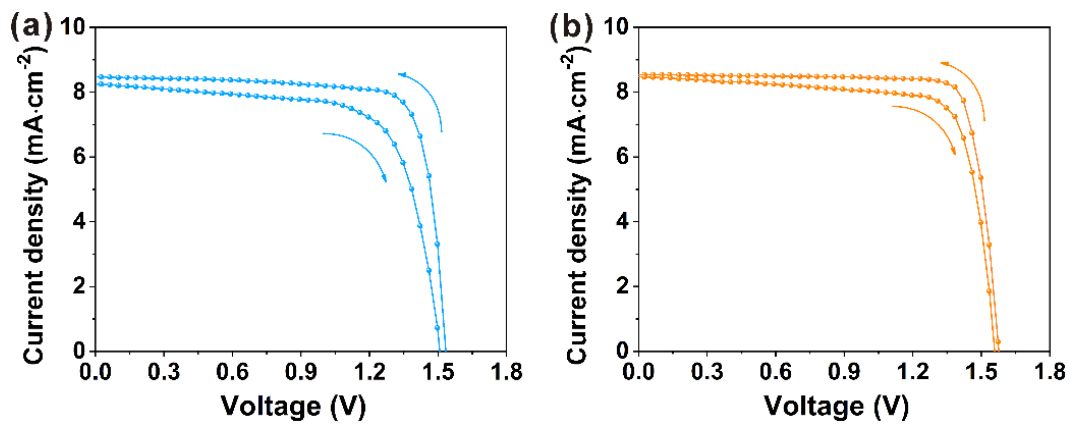


Fig. S24 The *J-V* curves of PSCs based on (a) CsPbBr₃ and (b) CsPbBr₃/DTPT under different scanning directions.

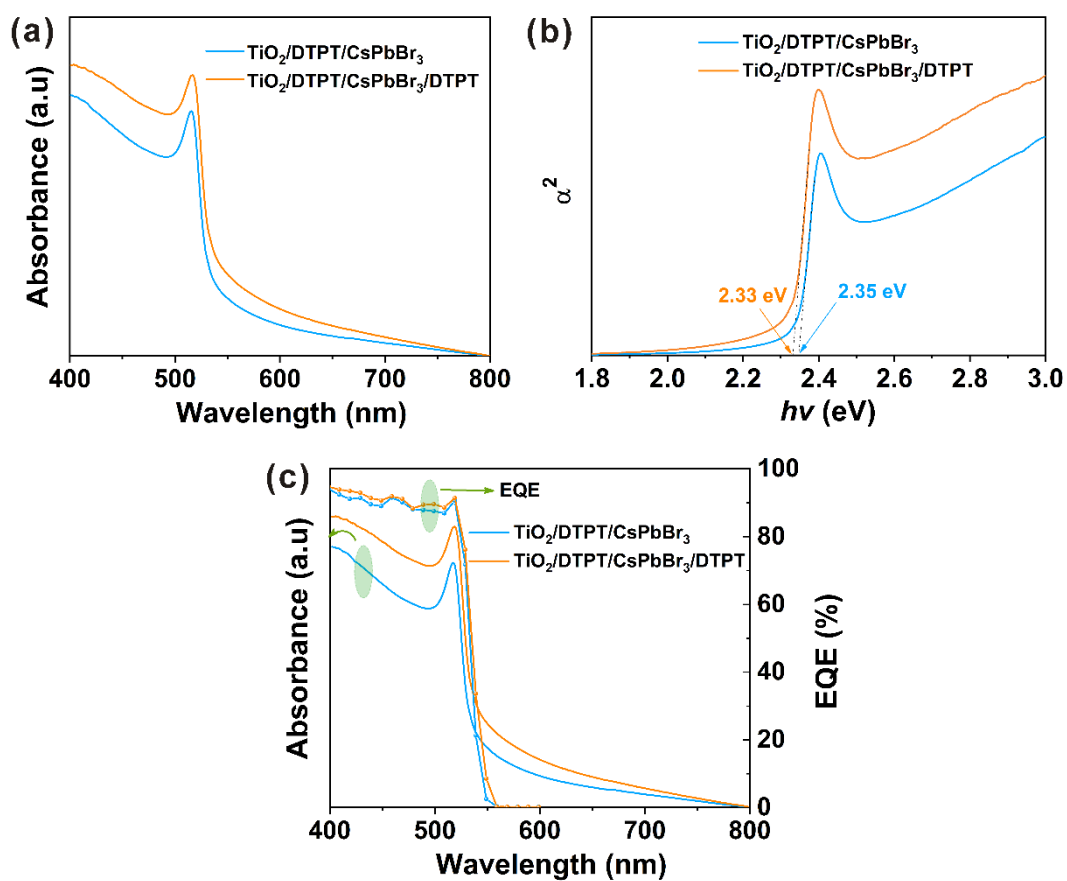


Fig. S25 (a) Absorption spectra and (b) Tauc plots of CsPbBr_3 and $\text{CsPbBr}_3/\text{DTPT}$ films deposited on TiO_2/DTPT films. (c) Absorption spectra and EQE spectra of CsPbBr_3 and $\text{CsPbBr}_3/\text{DTPT}$ films deposited on TiO_2/DTPT films.

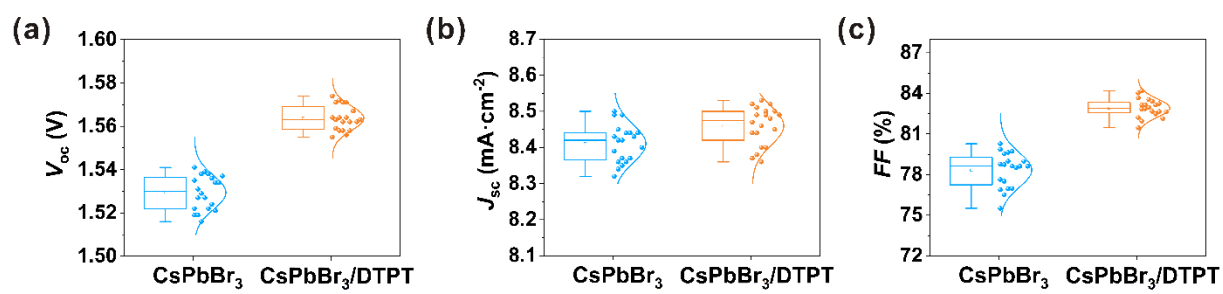


Fig. S26 Statistical (a) V_{oc} , (b) J_{sc} , and (c) FF of the devices with and without DTPT.

Supplementary Tables

Table S1. Photovoltaic parameters of PSCs based on TiO₂ and TiO₂/DTPT films.

Samples	Scan-direction	PCE (%)	V_{oc} (V)	J_{sc} (mA·cm ⁻²)	FF (%)
TiO ₂	backward	9.83	1.521	8.22	78.66
	forward	8.19	1.475	7.94	69.93
TiO ₂ /DTPT	backward	10.34	1.535	8.43	79.87
	forward	8.71	1.508	8.23	70.18

Table S2. Photovoltaic parameters of PSCs based on CsPbBr₃ and CsPbBr₃/DTPT.

Samples	Scan-direction	PCE (%)	V_{oc} (V)	J_{sc} (mA·cm ⁻²)	FF (%)
CsPbBr ₃	backward	10.34	1.535	8.43	79.87
	forward	8.71	1.508	8.23	70.18
CsPbBr ₃ /DTPT	backward	11.21	1.574	8.52	83.67
	forward	10.12	1.559	8.47	76.64

Table S3. Comparison of photovoltaic parameters for state-of-the-art CsPbBr₃ PSCs.

PSCs	PCE (%)	J_{sc} (mA cm ⁻²)	V_{oc} (V)	FF (%)	Ref.
FTO/TiO₂/DTPT/CsPbBr₃/DTPT/Carbon	11.21	8.52	1.574	83.67	This work
FTO/SnO ₂ -TiO _x Cl _{4-2x} /CsPbBr ₃ + Ti ₃ C ₂ Cl _x /Ti ₃ C ₂ Cl _x /Carbon	11.08	7.87	1.702	82.7	1
FTO/c-TiO ₂ /m-TiO ₂ /CsPbBr ₃ / CuInS ₂ /ZnS QDs/LPP-Carbon	10.85	7.73	1.626	86.3	2
FTO/c-TiO ₂ /m-TiO ₂ /GQDs/CsPbBr ₃ /Carbon	9.72	8.12	1.458	82.1	3
FTO/c-TiO ₂ /m-TiO ₂ /Sm ³⁺ -CsPbBr ₃ / Cu(Cr,Ba)O ₂ /Carbon	10.79	7.81	1.615	85.5	4
FTO/c-TiO ₂ /m-TiO ₂ /Sm ³⁺ -CsPbBr ₃ /Carbon	10.14	7.48	1.594	85.1	5
FTO/c-TiO ₂ /m-TiO ₂ /GQDs/CsPbBr ₃ /MnS/Carbon	10.45	8.28	1.52	83	6
FTO/c-TiO ₂ /m-TiO ₂ /CsPbBr ₃ /P1Z1/Carbon	10.03	7.652	1.578	83.06	7
FTO/c-TiO ₂ /PTI-CsPbBr ₃ /spiro-OMeTAD/Ag	10.91	9.78	1.498	74.47	8
FTO/c-TiO ₂ /CsPbBr ₃ /CsPbBr ₃ -CsPb ₂ Br ₅ /CsPbBr ₃ -Cs ₄ PbBr ₆ /Carbon	10.17	9.26	1.461	75.39	9
FTO/c-TiO ₂ /CsPbBr ₃ /Carbon	9.35	7.37	1.545	82.2	10
FTO/c-TiO ₂ /m-TiO ₂ /CsPb _{0.97} Tb _{0.03} Br ₃ /SnS:ZnS/NiO _x /carbon	10.26	8.21	1.57	79.6	11
FTO/SnO ₂ /CsPbBr ₃ /N-CQDs/Carbon	10.71	7.87	1.622	80.1	12
FTO/SnO ₂ /CsPbBr ₃ /CsSnBr ₃ /Carbon	10.60	7.80	1.610	84.4	13
FTO/SnO ₂ -TiO _x Cl _{4-2x} /WS ₂ /CsPbBr ₃ /Carbon	10.65	7.95	1.70	79	14
FTO/c-TiO ₂ /CsPbBr ₃ -CsPb ₂ Br ₅ /spiro-OMeTAD/Ag	8.34	8.48	1.296	75.9	15
FTO/c-TiO ₂ /m-TiO ₂ /CsPbBr _{2.98} Cl _{0.02} /Carbon	9.73	7.47	1.571	82.93	16

Table S4. Comparison of photovoltaic parameters for large-area CsPbBr₃ PSCs.

PSCs	Active area	Method	PCE (%)	J_{sc} (mA cm ⁻²)	V_{oc} (V)	FF (%)	Ref.
FTO/TiO ₂ /DTPT/CsPbBr ₃ /DTPT/Carbon	1 cm ²	Vapour deposition	9.18	7.81	1.509	77.85	This work
FTO/c-TiO ₂ /CsPbBr ₃ /spiro-OMeTAD/Au	1 cm ²	Vacuum evaporation	5.37	5.11	1.32	79.32	17
FTO/c-TiO ₂ /CsPbBr ₃ /CuPc/Carbon	1 cm ²	Vacuum evaporation	6.21	6.65	1.375	67.9	18
FTO/c-TiO ₂ /SnO ₂ /CsPbBr ₃ /CuPc/carbon	1 cm ²	Spin-coating	6.9	6.93	1.396	71.3	19
FTO/Ga-SnO ₂ /CsPbBr ₃ /Carbon	1 cm ²	Spin-coating	5.98	7.58	1.311	60.2	20
FTO/c-TiO ₂ /m-TiO ₂ /Cs _{0.91} Rb _{0.09} PbBr ₃ /Carbon	1 cm ²	Spin-coating	7.07	—	—	—	21

Supplementary References

- 1 Q. Zhou, J. Duan, J. Du, Q. Guo, Q. Zhang, X. Yang, Y. Duan and Q. Tang, *Adv. Sci.*, 2021, **8**, 2101418.
- 2 J. Duan, Y. Wang, X. Yang and Q. Tang, *Angew. Chem. Int. Ed.*, 2020, **59**, 4391-4395.
- 3 J. Duan, Y. Zhao, B. He and Q. Tang, *Angew. Chem. Int. Ed.*, 2018, **57**, 3787-3791.
- 4 J. Duan, Y. Zhao, Y. Wang, X. Yang, Q. Tang, *Angew. Chem. Int. Ed.*, 2019, **58**, 16147-16151.
- 5 J. Duan, Y. Zhao, X. Yang, Y. Wang, B. He and Q. Tang, *Adv. Energy Mater.*, 2018, **8**, 1802346.
- 6 X. Li, Y. Tan, H. Lai, S. Li, Y. Chen, S. Li, P. Xu and J. Yang, *ACS Appl. Mater. Interfaces*, 2019, **11**, 29746-29752.
- 7 Y. Liu, B. He, J. Duan, Y. Zhao, Y. Ding, M. Tang, H. Chen and Q. Tang, *J. Mater. Chem. A*, 2019, **7**, 12635-12644.
- 8 G. Tong, T. Chen, H. Li, L. Qiu, Z. Liu, Y. Dang, W. Song, L. K. Ono, Y. Jiang and Y. Qi, *Nano Energy*, 2019, **65**, 104015.
- 9 G. Tong, T. Chen, H. Li, W. Song, Y. Chang, J. Liu, L. Yu, J. Xu, Y. Qi and Y. Jiang, *Sol. RRL*, 2019, **3**, 1900030.
- 10 T. Xiang, Y. Zhang, H. Wu, J. Li, L. Yang, K. Wang, J. Xia, Z. Deng, J. Xiao, W. Li, Z. Ku, F. Huang, J. Zhong, Y. Peng and Y.-B. Cheng, *Sol. Energy Mater. Sol. Cells*, 2020, **206**, 110317.
- 11 H. Yuan, Y. Zhao, J. Duan, Y. Wang, X. Yang and Q. Tang, *J. Mater. Chem. A*, 2018, **6**, 24324-24329.
- 12 Y. Zhao, J. Duan, Y. Wang, X. Yang and Q. Tang, *Nano Energy*, 2020, **67**, 104286.
- 13 Y. Zhao, J. Duan, H. Yuan, Y. Wang, X. Yang, B. He and Q. Tang, *Sol. RRL*, 2019, **3**, 1800284.
- 14 Q. Zhou, J. Duan, X. Yang, Y. Duan and Q. Tang, *Angew. Chem. Int. Ed.*, 2020, **59**, 21997-22001.
- 15 H. Li, G. Tong, T. Chen, H. Zhu, G. Li, Y. Chang, L. Wang and Y. Jiang, *J. Mater. Chem. A*, 2018, **6**, 14255-14261.
- 16 X. Li, B. He, Z. Gong, J. Zhu, W. Zhang, H. Chen, Y. Duan and Q. Tang, *Sol. RRL*, 2020, **4**, 2000362.
- 17 J. Lei, F. Gao, H. Wang, J. Li, J. Jiang, X. Wu, R. Gao, Z. Yang and S. Liu, *Sol. Energy Mater. Sol. Cells*, 2018, **187**, 1-8.
- 18 X. Liu, X. Tan, Z. Liu, B. Sun, J. Li, S. Xi, T. Shi and G. Liao, *J. Power Sources*, 2019, **443**, 227269.
- 19 X. Liu, X. Tan, Z. Liu, H. Ye, B. Sun, T. Shi, Z. Tang and G. Liao, *Nano Energy*, 2019, **56**, 184-195.
- 20 Y. Zhao, Q. Deng, R. Guo, Z. Wu, Y. Li, Y. Duan, Y. Shen, W. Zhang and G. Shao, *ACS Appl. Mater. Interfaces*, 2020, **12**, 54904-54915.
- 21 Y. Li, J. Duan, H. Yuan, Y. Zhao, B. He and Q. Tang, *Sol. RRL*, 2018, **2**, 1800164.